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Application No.: 10/777,560 FORM 670-1449 (Modified) Attorney Docket No.: 108-18.1 LIST F PATENTS AND PUBLICATIONS FOR Applicant: Harry S. Luan, et al. PASPLICANT'S INFORMATION DISCLOSURE Filing Date: February 11, 2004 Group: STATEMENT (Use several sheets if necessary) Page 1 Reference Designation **U.S. PATENT DOCUMENTS** Filing Date Class Sub-class **Examiner Initial** Document No. Date (If Appropriate) 385 3/20/01 438 6,204,139 Liu et al 385 ÁΒ 6,531,371 3/11/03 Hsu et al 438 AC AD ΑE AF AG ΑH ΑI ΑJ ΑK ΑL AM AN ΑO FOREIGN PATENT DOCUMENTS Class Sub-class Translation Date Country Document No. (Yes/No) OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.) Zhuang et al., "Novell Colossal Magnetoresistive Thin Film Nonvolatile Resistance Random Access Memory (RRAM)," IEEE 2002. Liu et al., "A New Concept for Non-Volatile Memory: The Electric Pulse Induced Resistive Change Effect in Colossal Magnetoresistive Thin Films," Liu et al., "Electric-pulse-induced reversible resistance change effect in magnetoresistive films," American AR Institute of Physics, 2000, pg. 2749-2751. AS ΑT ΑU A٧ ΑW ΑX 3 26 EXAMINER DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.